

IPN



PATENT  
Customer No. 22,852  
Attorney Docket No. 08244.0009-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
 )  
Ki-Seon PARK et al. ) Group Art Unit: 2813  
 )  
Application No.: 10/728,855 ) Examiner: Smoot, Stephen W.  
 )  
Filed: December 8, 2003 ) Confirmation No. 9300  
 )  
For: METHOD FOR MANUFACTURING )  
A SEMICONDUCTOR DEVICE )  
FOR USE IN A MEMORY CELL )  
THAT INCLUDES FORMING A )  
COMPOSITE LAYER OF )  
TANTALUM OXIDE AND )  
TITANIUM OXIDE OVER A )  
BOTTOM CAPACITOR )  
ELECTRODE (AS AMENDED) )

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**AMENDMENT**

In reply to the Ex parte Quayle Action mailed June 20, 2005, the period for response to which extends through August 22, 2005 (August 20, 2005 being a Saturday), please amend the above-identified application as follows:

**An Amendment to the Specification** is reflected on page 2 of this paper.

**Amendments to the Claims** are reflected in the listing of claims beginning on page 3 of this paper.

**Remarks** follow the **Amendment to the Claims** section and begin on page 8 of this paper.